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I Introduction

At present, finding new types of pollution-free renewable energy has become a hot topic.¹⁻⁴ In recent years, since hydrogen gas has the advantages of stable chemical properties at normal temperature, high combustion heat value and no pollution of the combustion product, it has gained more and more attention and is expected to replace traditional fossil fuels.⁵⁻⁸ Hydrogen in nature is mainly stored in water in the form of compounds. Therefore, it is an effective way to produce hydrogen gas by photocatalytic water splitting.9-15 Currently, various types of photocatalysts have been researched extensively, mainly focusing on these two types: oxides represented by TiO₂,^{16,17} ZnO¹⁸ and WO₃,¹⁹ and sulfides represented by CdS²⁰ and ZnS.²¹ However, most oxides have the disadvantages of excessively wide bandgap (E_g) and low light-absorption efficiency. Although the sulfides have narrow E_{g} values, it is easily etched by light during photocatalysis. For example, although CdS has a suitable E_g and band-edge position, the S²⁻ in CdS is more easily oxidized by photogenerated holes

The In₂SeS/g-C₃N₄ heterostructure: a new two-dimensional material for photocatalytic water splitting[†]

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In this work, the structural, electronic and optical properties of the $ln_2SeS/g-C_3N_4$ heterostructure are investigated to explore a highly efficient and spontaneous water splitting photocatalyst by first-principles calculations. The results show that the $ln_2SeS/g-C_3N_4$ heterostructure with a bandgap (E_g) of 2.03 eV is a typical type II semiconductor, which guarantees that the generated electrons and holes can be effectively separated. The potential of the conduction band minimum (CBM) and the valence band maximum (VBM) satisfies the requirements for photocatalytic water splitting. Meanwhile, the $ln_2SeS/g-C_3N_4$ heterostructure has a strong light-absorption ability, and mainly absorbs purple and blue light. In addition, the changes of Gibbs free energy (ΔG) are calculated to understand the oxygen evolution reaction (OER) process of water splitting. Under neutral conditions (pH = 7), the Gibbs free energy continuously decreases during the OER process, verifying the thermodynamic feasibility of water splitting through the $ln_2SeS/g-C_3N_4$ heterostructure. Hence, the $ln_2SeS/g-C_3N_4$ heterostructure is a kind of photocatalyst with excellent performance in the area of photocatalytic water splitting.

than the water molecule, which results in the production of S.²² Moreover, the electrons and holes of these oxides and sulfides are very easy to recombine. These disadvantages limit the practical applications in the field of photocatalytic water splitting.²³ Therefore, it is necessary to explore a new type of photocatalyst that can absorb sunlight efficiently and separate the electrons and holes easily.

The polymeric graphite-like carbon nitride $(g-C_3N_4)$ is a twodimensional (2D) layered semiconductor with non-toxicity, chemical stability, low cost and high sensitivity to sunlight.²⁴⁻²⁶ Interestingly, g-C₃N₄ has relatively large vacancies and enough adsorption sites.^{27,28} Meanwhile, monolayer InM (M = S, Se) has tunable E_{g} , high sensitivity to sunlight and high carrier mobility compared to most 2D materials.^{29,30} Therefore, both g-C₃N₄ and monolayer InM (M = S, Se) have great potential for photocatalytic water splitting. However, the photogenerated electrons and holes of $g-C_3N_4$ and monolayer InM (M = S, Se) also recombine easily, limiting their application in photocatalytic water splitting. To date, the construction of van der Waals (vdW) heterostructures is considered to be an effective way to modify the atomic and electronic structures of the photocatalysts, which accelerates the separation and transmission of the electrons and holes.³¹ For example, SnSe₂/WSe₂ vdW heterostructures have been successfully applied to prevent the photogenerated electrons and holes from recombining.32 Therefore, in this work, we consider designing vdW In2SeS/g-C3N4 heterostructures to effectively prevent the recombination of photogenerated

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electrons and holes and making them retain high sensitivity to sunlight and high carrier mobility.

Herein, first, the most stable structure of the In₂SeS/g-C₃N₄ heterostructure is found through geometric optimization. Then, we have analyzed the electronic and optical properties of the In₂SeS/g-C₃N₄ heterostructure, and found that it is a typical type II semiconductor, and mainly absorbs blue and purple light. Furthermore, in order to investigate the thermodynamic feasibility of photocatalytic water splitting, the changes in Gibbs free energy (ΔG) are calculated during the oxygen evolution reaction (OER) that occurred on the g-C₃N₄ layer side. The results show that the In₂SeS/g-C₃N₄ heterostructure is a kind of photocatalyst with excellent performance in the area of photocatalytic water splitting.

II Theoretical approach

The first-principles calculations were performed by the Vienna Ab initio Simulation Package (VASP) with the projector augmented wave (PAW), based on density functional theory (DFT).^{33,34} The generalized gradient approximation (GGA) and Perdew-Burke-Ernzerh (PBE) were adopted to treat the exchange-correlation interaction of electrons.35,36 Because of the underestimation of the PBE functional on the band gap of the semiconductor, the HSE06³⁷ hybrid functional was applied for calculations of more accurate electronic properties. Meanwhile, the GW^{38,39} approximation combined with the Bethe-Salpeter equation (BSE)⁴⁰ was employed to predict the optical properties. In addition, considering the vdW interactions between the layers, the empirical correction scheme of the DFT-D3 (D stands for dispersion) approach within the Grimme scheme was adopted.⁴¹ A vacuum spacing of 25 Å was added along the direction perpendicular to 2D nanosheets to avoid the interlayer interactions caused by periodicity. A Monkhorst-Pack k-point mesh of $7 \times 7 \times 1$ was used to calculate the properties of all studied samples in the 2D Brillouin zone. The cut-off energy was set to 600 eV. The convergence tolerances for energy, maximum force and displacement on each atom during structural relaxation were set to 10^{-5} eV, 0.03 eV Å⁻¹ and 0.003 Å, respectively.

III Results and discussion

3.1 Structures and stabilities of In₂SeS/g-C₃N₄

The calculated lattice parameters of g-C₃N₄ (a = b = 7.06 Å) and monolayer In₂SeS (a = b = 3.95 Å) are in good agreement with the other theoretical calculations and experimental result.^{42,43} Meanwhile, the phonon spectrum of monolayer In₂SeS is shown in Fig. S1 (ESI†). There is no virtual frequency in the phonon spectrum, which proves that the optimized structure of monolayer In₂SeS is stable. The In₂SeS/g-C₃N₄ vdW heterostructure is achieved by a 1 × 1 g-C₃N₄ supercell and a $\sqrt{3} \times \sqrt{3}$ monolayer In₂SeS supercell stacked in the vertical direction with a lattice mismatch of about 3%. According to the different stacking patterns of g-C₃N₄ and monolayer In₂SeS, twelve

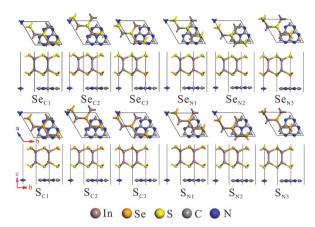


Fig. 1 Top and side views of the $In_2SeS/g-C_3N_4$ heterostructure at different stacking patterns: $Se_{C1},\ Se_{C2},\ Se_{C3},\ Se_{N1},\ Se_{N2},\ Se_{N3},\ S_{C1},\ S_{C2},\ S_{C3},\ S_{N1},\ S_{N2}$ and $S_{N3}.$

different heterostructures are constructed, as shown in Fig. 1. When Se atoms are adjacent to the g-C₃N₄ layer and C or N atoms are located in the hexagonal ring center of the In₂SeS layer, the heterostructures are labeled as Se_{C1}, Se_{C2}, Se_{C3}, Se_{N1}, Se_{N2} and Se_{N3}. When S atoms are adjacent to the g-C₃N₄ layer and C or N atoms are located in the hexagonal ring center of the In₂SeS layer, the heterostructures are labeled as S_{C1}, S_{C2}, S_{C3}, S_{N1}, S_{N2} and S_{N3}. To check the stability of the structure, the binding energy (*E*_b) of the 12 heterostructures are calculated using the following formula:⁴⁴

$$E_{\rm b} = E_{\rm g-C_3N_4/In_2SeS} - E_{\rm g-C_3N_4} - E_{\rm In_2SeS}$$
(1)

where $E_{\text{g-C}_3\text{N}_4/\text{In}_2\text{SeS}}$, $E_{\text{g-C}_3\text{N}_4}$ and $E_{\text{In}_2\text{SeS}}$ represent the total energy of the In₂Se/g-C₃N₄ heterostructure, g-C₃N₄ and monolayer In₂SeS, respectively. According to the definition, a negative value of $E_{\rm b}$ indicates that the heterostructure system is energetically stable. Meanwhile, the more negative the value of $E_{\rm b}$ is, the more stable the heterostructure is. Therefore, as shown in Table 1, the smallest $E_{\rm b}$ (-2.21 eV) of the S_{N1} stacking pattern means that it is the most stable among the twelve stacking patterns. Moreover, to find the most suitable interlayer distance (d_0) of the S_{N1} stacking pattern, $E_{\rm b}$ of the S_{N1} stacking pattern is calculated as a function of d_0 , which is shown in Fig. S2 (ESI†). When $d_0 = 3$ Å, $E_{\rm b}$ is -2.29 eV, and it is the most negative value among them. Thus the S_{N1} stacking pattern with a d_0 of 3 Å is the most stable. As shown in Table S1 (ESI†), the convergence

Table 1 Interlayer spacing and binding energy of the $\mbox{In}_2\mbox{Se}/\mbox{g}-\mbox{C}_3\mbox{N}_4$ heterostructure

Туре	In ₂ SeS/g-C ₃ N ₄					
Stacking patterns	Se _{C1}	Se _{C2}	Se _{C3}	Se _{N1}	Se _{N2}	Se _{N3}
$E_{\rm b}$ (eV)	-2.161	-1.422	-2.044	-1.295	-1.505	-1.520
d_0 (Å)	2.872	2.847	2.830	3.142	3.134	2.667
Stacking patterns	S _{C1}	S _{C2}	S _{C3}	S _{N1}	S _{N2}	S _{N3}
$E_{\rm b}$ (eV)	-2.128	-2.108	-2.092	-2.210	-1.462	-1.948
d_0 (Å)	2.731	2.783	2.781	2.848	3.041	3.042

test results also show that the $S_{\rm N1}$ stacking pattern is stable, so it is chosen for further calculation.

3.2 Electronic properties of In₂SeS/g-C₃N₄

In order to investigate the electronic properties of the In₂SeS/g-C₃N₄ heterostructure, the charge distribution and charge transfer are considered by analyzing the planar average charge density ($\rho(z)$) and the planar average charge density difference ($\Delta \rho(z)$). $\Delta \rho(z)$ is given by the following formula:⁴⁵

$$\Delta \rho(z) = \rho(z)_{\ln_2 SeS/g-C_3N_4} - \rho(z)_{g-C_3N_4} - \rho(z)_{\ln_2 SeS}$$
(2)

where $\rho(z)_{In_2SeS/g-C_3N_4}$, $\rho(z)_{g-C_3N_4}$ and $\rho(z)_{In_2SeS}$ are $\rho(z)$ of the In₂SeS/g-C₃N₄ heterostructure, g-C₃N₄ and monolayer In₂SeS, respectively. In Fig. S3 (ESI[†]), $\rho(z)$ values of g-C₃N₄, monolayer In₂SeS and the In₂SeS/g-C₃N₄ heterostructure are given. In Fig. 2, we can see that charges accumulate in the In₂SeS layer and dissipates in the g-C₃N₄ layer, indicating that electrons are transferred from the g-C₃N₄ layer to the In₂SeS layer. Thus the electrons and holes are effectively separated, which is conducive to the water splitting of the In₂SeS/g-C₃N₄ heterostructure. To further study the interfacial electronic properties, the interface dipole moment $\mu(z)$ is also calculated using the following formula:⁴⁵

$$\mu(z) = \int z \Delta \rho(z) \mathrm{d}z \tag{3}$$

A μ (z) of -0.23 D from the g-C₃N₄ layer to the In₂SeS layer is found by calculation, confirming the formation of a heterostructure-induced interface dipole.

Moreover, the energy bands of g-C₃N₄, monolayer In₂SeS and the In₂SeS/g-C₃N₄ heterostructure are calculated, as shown in Fig. 3. Both g-C₃N₄ and monolayer In₂SeS are indirect bandgap semiconductors with E_g values of 2.67 eV and 2.33 eV at the HSE06 level, respectively. Surprisingly, the In₂SeS/g-C₃N₄ heterostructure is a direct bandgap semiconductor with an E_g of 2.03 eV, which is in the energy range of visible light (1.6–3.2 eV). Meanwhile, the top band of the valence band is mainly contributed by the g-C₃N₄ layer and the bottom band of the conduction band is mainly contributed by the In₂SeS layer, which indicates that the

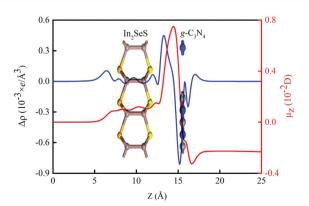


Fig. 2 Planar average charge density difference (blue line) and interfacial dipole moment (red line) along the Z-direction for the $In_2SeS/g-C_3N_4$ heterostructure.

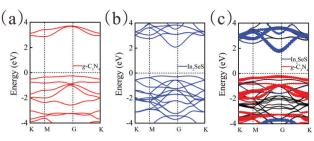


Fig. 3 (a) Band structure of $g-C_3N_4$. (b) Band structure of monolayer In₂SeS. (c) Band structure of the In₂SeS/ $g-C_3N_4$ heterostructure.

electrons and holes are separated after the formation of the heterostructure and the $In_2SeS/g-C_3N_4$ heterostructure is a type-II heterostructure. Meanwhile, the total density of states (TDOS) and the projected density of states (PDOS) for the $In_2SeS/g-C_3N_4$ heterostructure are calculated. As shown in Fig. 4, the peak with the highest energy below the Fermi level is basically provided by the N–p orbit while the peak with the lowest energy above the Fermi level is basically provided by the In–s orbit, which implies that the positions of N and In atoms are better adsorption sites and also illustrates the separation of electrons and holes.

Furthermore, the carrier mobility (μ) of the In₂SeS/g-C₃N₄ heterostructure is also calculated using the formula^{46–49}

$$\mu_{2D} = \frac{e^3 C_{2D}}{k_b T (m^*)^2 (E_l^i)^2}$$
(4)

where *e* is the electron charge, \hbar is Planck's constant divided by 2π and $k_{\rm b}$ is Boltzmann's constant. *T* is the temperature, which is set to 298.15 K in our calculation to simulate room temperature. *m*^{*} is the effective mass of an electron or hole, which is calculated using the formula

$$\frac{1}{m^*} = \frac{1}{h^2} \frac{\partial^2 E(k)}{k^2} \tag{5}$$

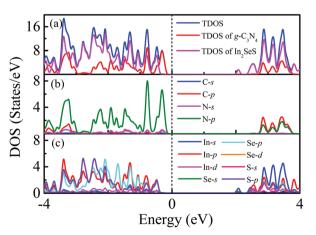


Fig. 4 (a) TDOS of the In₂SeS/g-C₃N₄ heterostructure, PDOS of the g-C₃N₄ layer in the In₂SeS/g-C₃N₄ heterostructure and PDOS of the In₂SeS layer in the In₂SeS/g-C₃N₄ heterostructure. (b) PDOS of C and N atoms in the g-C₃N₄ layer. (c) PDOS of In, Se and S atoms in the In₂SeS layer.

where *E* is the total energy and *k* is the wave vector. Then, C_{2D} is the 2D elastic modulus, which is calculated using the formula

$$\frac{E - E_0}{S_0} = C_{2D} \frac{(\Delta l/l_0)^2}{2}$$
(6)

where *E* and *E*₀ are the total energy of the crystal with and without deformation and *S*₀ is the lattice volume of the equilibrium state. Δl and *l*₀ are the variation of the lattice length and the initial lattice length, respectively. Then, *E*ⁱ₁ is the deformation potential constant of the valence band maximum (VBM) for holes or the conduction band minimum (CBM) for electrons along the transport direction, which is calculated using the formula

$$E_{1}^{i} = \frac{\Delta V_{i}}{\Delta l/l_{0}} \tag{7}$$

where ΔV_i is the energy change of the *i*th band under compression and tension. According to the above formula, the effective mass of the electrons and holes are $0.114m_0$ and $1.36m_0$, respectively. Energy changes of the In₂SeS/g-C₃N₄ heterostructure with strains in the X-direction and the Y-direction are given, as shown in Fig. S4 (ESI^{\dagger}). C_{2D} values are both 87.89 J m⁻² along the X-direction and the Y-direction by calculation, and the electron and hole mobilities are 1665 $\text{cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ and $12 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, respectively. The electron mobility is a relatively large value compared to other 2D materials, which is conducive to photocatalytic water splitting. Meanwhile, we have calculated the effective mass and carrier mobility of the In₂SeS/g-C₃N₄ heterostructure with a strain (from -3% to 3%) applied in the X-direction and the Y-direction, respectively, as shown in Table S2 (ESI⁺). It is found that the strain has little effect on the carrier mobility of the In₂SeS/g-C₃N₄ heterostructure.

Then, the electrostatic potentials of g-C₃N₄, monolayer In₂SeS and the In₂SeS/g-C₃N₄ heterostructure are calculated. Moreover, their work function (φ) is also calculated, which is given by the formula

$$\varphi = E_{\rm vac} - E_{\rm f} \tag{8}$$

where E_{vac} is the electrostatic potential in a vacuum near to the surface. $E_{\rm f}$ is the electrostatic potential at the Fermi level. As shown in Fig. 5, φ values of g-C₃N₄, monolayer In₂SeS and the In₂SeS/g-C₃N₄ heterostructure are 5.38 eV, 6.19 eV and 5.93 eV, respectively, which means that the g-C₃N₄ layer is easier to lose electrons than the In₂SeS layer. Moreover, the standard oxidation potential of O_2/H_2O can be calculated using $E_{O_2/H_2O} = -5.67 \text{ eV} +$ pH \times 0.059 eV and the standard hydrogen potential of H⁺/H₂ can be calculated using $E_{\text{H}^+/\text{H}_2} = -4.44 \text{ eV} + \text{pH} \times 0.059 \text{ eV}.^{50,51}$ To satisfy the requirements for photocatalytic water splitting, the potential of the CBM for photocatalysts should be higher than the standard hydrogen potential and the potential of the VBM for photocatalysts should be lower than the standard oxygen potential.⁵² Therefore, based on the value of φ , we have obtained the potentials at the Fermi level for g-C₃N₄, monolayer In₂SeS and the $In_2SeS/g-C_3N_4$ heterostructure. Their values are -5.38 eV, -6.19 eV and -5.93 eV, respectively. Then, based on the relative positions of the CBM, the VBM and the Fermi level (obtained

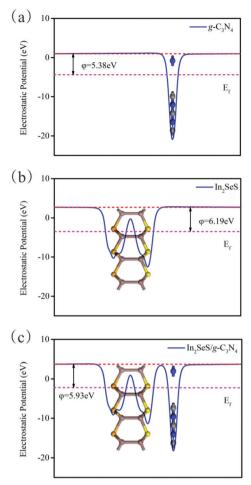


Fig. 5 (a) Electrostatic potential of $g-C_3N_4$. (b) Electrostatic potential of monolayer In_2SeS . (c) Electrostatic potential of the $In_2SeS/g-C_3N_4$ heterostructure. The red and pink dashed lines denote the Fermi level and the vacuum energy level, respectively.

according to Fig. 3), we have calculated the potentials of bandedge positions for g-C₃N₄, monolayer In₂SeS and the In₂SeS/g-C₃N₄ heterostructure, as shown in Fig. 6. The values of potential at CBM and at VBM for g-C₃N₄ are -3.25 eV and -5.92 eV,

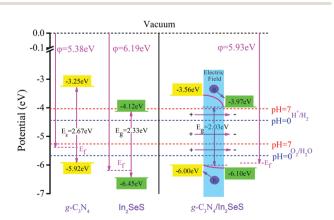


Fig. 6 Potential of band-edge positions for g-C_3N_4, monolayer In_2SeS and the In_2SeS/g-C_3N_4 heterostructure.

respectively. The values of potential at the CBM and at the VBM for monolayer In₂SeS are -4.12 eV and -6.45 eV, respectively. After the heterostructure is formed, the value of the potential at the CBM for the In₂SeS/g-C₃N₄ heterostructure is 3.97 eV, which is higher than the standard hydrogen potential (4.44 eV at pH = 0and 4.01 eV at pH = 7). In addition, the value of the potential at the VBM for the In₂SeS/g-C₃N₄ heterostructure is 6.00 eV, which is lower than the standard oxygen potential (5.67 eV at pH = 0 and 5.26 eV at pH = 7). Therefore, in terms of potential, the In_2SeS/g -C₃N₄ heterostructure meets the requirements for photocatalytic water splitting. Part electrons are transferred from the g-C₃N₄ layer to the In₂SeS layer, which leads to the formation of an internal electric field from the g-C₃N₄ layer to the In₂SeS layer. The g-C₃N₄ layer is similar to the anode when electrolyzing water and the oxygen evolution reaction (OER) occurs. The In₂SeS layer is similar to the cathode of electrolyzing water and the hydrogen evolution reaction (HER) occurs.

Besides, the In₂SeS/g-C₃N₄ heterostructure is applied with biaxial strain. We find that the In₂SeS/g-C₃N₄ heterostructure can withstand the biaxial strain from -6% to +6% without damaging its structure. As shown in Fig. 7, when the values of biaxial strain are -6%, -4%, -2%, 2%, 4% and 6%, the $E_{\rm g}$ values of the In₂SeS/g-C₃N₄ heterostructure are 3.16 eV, 3.01 eV, 2.64 eV, 1.83 eV, 1.51 eV and 1.19 eV, respectively. It is concluded that E_{g} increases with the decrease of biaxial strain and $E_{\rm g}$ decreases with the increase of biaxial strain. Among them, when the value of biaxial strain is 2%, the In₂SeS/g-C₃N₄ heterostructure is still a direct bandgap semiconductor. When the tensile stress is greater than 2% or compressive stress is applied, the In₂SeS/g-C₃N₄ heterostructure will have a transition from a direct bandgap semiconductor to an indirect bandgap semiconductor. The potentials of band-edge positions under different biaxial strain conditions are shown in Fig. 8. When -6%, -4%, -2% and 2% biaxial strains are applied, the potentials of the VBM and the CBM still satisfy the requirements for photocatalytic water splitting. When 4% and 6% biaxial strains are applied, the potentials of the VBM and the CBM cannot satisfy the requirements for photocatalytic water splitting. It is noted that the larger the E_g of the heterostructure is, the greater the driving force for photocatalytic water splitting is. However, once E_{g} is too large, the energy required for electronic transition from the valence band to the conduction

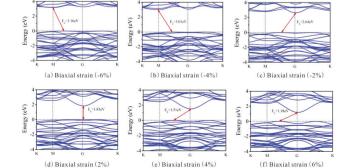


Fig. 7 Band structure under different biaxial strain conditions.

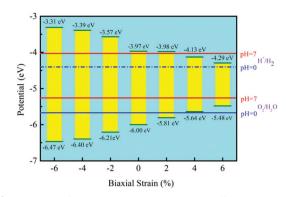


Fig. 8 Potential of band-edge positions under different biaxial strain conditions.

band increases and the wavelength range of sunlight that can provide sufficient energy reduces, which is not conducive to photocatalytic water splitting. Therefore, when -2% biaxial strain is applied, the effect of the In₂SeS/g-C₃N₄ heterostructure for photocatalytic water splitting is the best in theory.

3.3 Optical properties of In₂SeS/g-C₃N₄

In addition, the optical properties of the In₂SeS/g-C₃N₄ heterostructure are predicted by using the GW+BSE approach. The real part (ε_1) and the imaginary part (ε_2) describe the dielectric properties and light-absorption ability of the material, respectively. The imaginary part (ε_2) can be determined using the formula^{53–55}

$$\varepsilon_2(\omega) = \frac{2e^2\pi}{\Omega\varepsilon_0} \sum_{k,c,\nu} \left| \left\{ \psi_k^c |\mu \cdot r| \psi_k^\nu \right\} \right|^2 \delta \left(E_k^c - E_k^\nu - E \right)$$
(9)

where ω represents the frequency of the electromagnetic radiation in energy units. Ω and ε_0 represent the cell volume and the dielectric constant in free space, respectively. c and v represent the conduction and valence band states, respectively. u and rrepresent the vector defining the polarization of the incident electric field and the position vector, respectively. As shown in Fig. 9, the light-absorption ability of the In₂SeS/g-C₃N₄

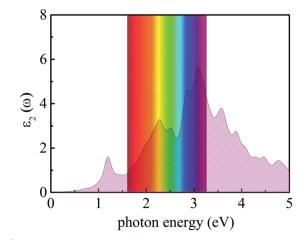


Fig. 9 Absorption spectrum of light.

heterostructure is relatively strong. The highest light-absorption peak is between blue and purple light (corresponding to a photon energy of about 3 eV, and $E_{\rm g}$ of the In₂SeS/g-C₃N₄ heterostructure is 2.03 eV), which indicates that after the In₂SeS/g-C₃N₄ heterostructure absorbs the photons, there is enough energy to promote the electron to transit from the valence band to the conduction band.

3.4 Thermodynamic feasibility of the In₂SeS/g-C₃N₄ heterostructure for photocatalytic water splitting

Finally, we have explored the thermodynamic feasibility of the $In_2SeS/g-C_3N_4$ heterostructure for photocatalytic water splitting. The reaction of water splitting can be divided into two half reactions: the HER in the cathode and the OER in the anode. The reaction step of the HER is:²⁸

$$2\mathrm{H}^{+} + 2\mathrm{e}^{-} \to \mathrm{H}_{2} \tag{10}$$

and the OER is divided into 4 small steps:^{56,57}

$$H_2O + * \rightarrow OH^* + H^+ + e^-$$
 (11a)

$$OH^* + H^+ + e^- \rightarrow O^* + 2(H^+ + e^-)$$
 (11b)

$$O^* + H_2O + 2(H^+ + e^-) = OOH^* + 3(H^+ + e^-)$$
 (11c)

where * indicates the In₂SeS/g-C₃N₄ heterostructure substrate. OH*, O* and OOH* indicate that OH, O and OOH are adsorbed on the substrate, respectively. ΔG is calculated using the formula^{58,59}

$$\Delta G = \Delta E + \Delta Z P E - T \Delta S - \Delta G_{\rm U} - \Delta G_{\rm pH}$$
(12)

where ΔE represents the change in total energy. ΔZPE represents the change in zero point energy. ZPE could be calculated by

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$$ZPE = 1/2 \sum h\nu \tag{13}$$

where ν represents the vibrational frequency. Then, $T\Delta S$ represents the change in entropic contributions (*T* is set to be 298.15 K). TS could be calculated by

$$TS = k_b T \left[\sum_{K} \ln\left(\frac{1}{1 - e^{-h\nu/k_b T}}\right) + \sum_{K} \frac{h\nu}{k_b T} \left(\frac{1}{e^{h\nu/k_b T} - 1}\right) + 1 \right]$$
(14)

where *e* represents the electron charge, *h* represents Planck's constant and $k_{\rm b}$ is Boltzmann's constant. Then, $\Delta G_{\rm U}$ represents the effect of electrochemical potential on ΔG , which is calculated by:

$$\Delta G_{\rm U} = -eU \tag{15}$$

where *U* represents the potential difference from the standard hydrogen electrode potential. Then, ΔG_{pH} represents the effect of the pH value on ΔG , which is calculated by:

$$\Delta G_{\rm pH} = -k_{\rm b} T \ln 10 \times \rm pH \tag{16}$$

Here, pH = 0 and pH = 7 are considered. Theoretically, the HER is relatively easy under the action of the potential and thus we only need to consider the feasibility of the OER in thermodynamics. Fig. 10(a)–(c) show the most stable adsorption site of OH, O and OOH on the g-C₃N₄ side of the In₂SeS/g-C₃N₄ heterostructure, respectively. In Fig. 10(d), when pH = 0, U = 0 V, ΔG increases every step to 4.55 eV eventually. When pH = 0 and U = 1.23 V (minimum potential difference required for water splitting), ΔG declines in the first and third reactions while it increases in the second and fourth reactions. The actual electrochemical driving force of the OER is 1.56 eV at pH = 0 (potential difference between the potential of the VBM and the standard hydrogen potential). When pH = 0 and U = 1.56 V, ΔG declines in

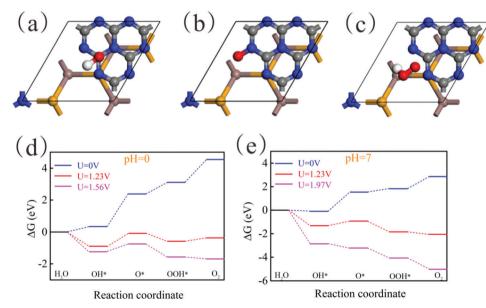


Fig. 10 (a)–(c) Optimized geometries of OH, O and OOH on the $In_2SeS/g-C_3N_4$ heterostructure during OER. (d) The changes of Gibbs free energy at pH = 0 and at different potential differences (0 V, 1.23 V and 1.56 V). (e) The changes of Gibbs free energy at pH = 7 and at different potential differences (0 V, 1.23 V and 1.56 V). (e) The changes of Gibbs free energy at pH = 7 and at different potential differences (0 V, 1.23 V and 1.56 V).

the first, third and fourth reactions while it increases in the second reaction. In all, when pH = 0, the existence of the increase of ΔG leads to the failure of water splitting for the In₂SeS/g-C₃N₄ heterostructure in thermodynamics. In Fig. 10(e), when pH = 7 and U = 0 V, ΔG increases every step to 2.86 eV eventually. When pH = 7 and U = 1.23 V, ΔG declines in the first, third and fourth reactions while it increases in the second reaction. Therefore, when pH = 7, U = 0 or 1.23 eV, it is also impossible to split water for the In₂SeS/g-C₃N₄ heterostructure in thermodynamics. The actual electrochemical driving force of the OER is 1.56 eV at pH = 7. When pH = 7 and U = 1.97 V, ΔG declines every step of the OER, which indicates that the In₂SeS/g-C₃N₄ heterostructure for photocatalytic water splitting becomes feasible in thermodynamics under this condition.

IV Conclusions

Twelve structures of the In2SeS/g-C3N4 heterostructures are constructed according to different stacking patterns. Through the first-principles calculations, we find that the S_{N1} stacking pattern of the In₂SeS/g-C₃N₄ heterostructure with a d_0 of 3 Å is the most stable, and the In₂SeS/g-C₃N₄ heterostructure is a typical type-II semiconductor with a direct bandgap of 2.03 eV, whose CBM and VBM are contributed by the In₂SeS layer and the g-C₃N₄ layer, respectively. The potentials at the CBM and the VBM satisfy the requirements for photocatalytic water splitting. The electron mobility is 1665 $\text{cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, which is a relatively large value compared to other 2D materials. Meanwhile, the In₂SeS/g-C₃N₄ heterostructure has a strong ability to absorb light, mainly absorbing blue and purple light. In addition, when pH = 7 and U = 1.97 V, ΔG goes down every step of the OER, which verifies the feasibility of photocatalytic water splitting in thermodynamics. In short, the In₂SeS/g-C₃N₄ heterostructure is expected to be a good candidate for photocatalytic water splitting.

Conflicts of interest

There are no conflicts to declare.

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Notes and references

- 1 J. W. Ager and A. A. Lapkin, Science, 2018, 360, 707-708.
- 2 X. J. Huang, Q. B. Meng, H. Chen, X. L. Du and L. Q. Chen, *Science*, 2018, **360**, 47–51.
- 3 Y. Zhou and Y. S. Liu, Nature, 2018, 560, 29.

- 4 S. G. Anton and A. E. A. Nucu, *Renewable Energy*, 2020, **147**, 330–338.
- 5 F. Gutierrez-Martin, A. B. Calcerrada, A. de Lucas-Consuegra and F. Dorado, *Renewable Energy*, 2020, **147**, 639–649.
- 6 H. Mehrjerdi, A. Iqbal, E. Rakhshani and J. R. Torres, *Energy Convers. Manage.*, 2019, **201**, 11.
- 7 H. Ishaq and I. Dincer, J. Cleaner Prod., 2020, 246, 12.
- 8 C. J. Quarton, O. Tlili, L. Welder, C. Mansilla, H. Blanco, H. Heinrichs, J. Leaver, N. J. Samsatli, P. Lucchese, M. Robinius and S. Samsatli, *Sustainable Energy Fuels*, 2020, 4, 80–95.
- 9 M. Chauhan, K. Soni, P. E. Karthik, K. P. Reddy, C. S. Gopinath and S. Deka, *J. Mater. Chem. A*, 2019, 7, 6985–6994.
- 10 Y. J. Wu, C. B. Cao, C. Qiao, Y. Wu, L. F. Yang and W. Younas, J. Mater. Chem. C, 2019, 7, 10613–10622.
- 11 J. Z. Liu, Y. H. Li, X. D. Zhou, H. Jiang, H. G. Yang and C. Z. Li, *J. Mater. Chem. A*, 2020, 8, 17–26.
- 12 J. Zhu, M. Sun, S. J. Liu, X. H. Liu, K. Hu and L. Wang, J. Mater. Chem. A, 2019, 7, 26975–26983.
- 13 K. Maeda, K. Teramura, D. L. Lu, T. Takata, N. Saito, Y. Inoue and K. Domen, *Nature*, 2006, **440**, 295.
- 14 F. F. Hu, L. Q. Tao, H. Y. Ye, X. D. Li and X. P. Chen, J. Mater. Chem. C, 2019, 7, 7104–7113.
- 15 T. Hisatomi, J. Kubota and K. Domen, *Chem. Soc. Rev.*, 2014, 43, 7520–7535.
- 16 S. Cao, T. S. Chan, Y. R. Lu, X. H. Shi, B. Fu, Z. J. Wu, H. M. Li, K. Liu, S. Alzuabi, P. Cheng, M. Liu, T. Li, X. B. Chen and L. Y. Piao, *Nano Energy*, 2020, **67**, 9.
- 17 Y. Li, Q. Q. Shen, R. F. Guan, J. B. Xue, X. G. Liu, H. S. Jia, B. S. Xu and Y. C. Wu, *J. Mater. Chem. C*, 2020, 8, 1025–1040.
- 18 V. Etacheri, R. Roshan and V. Kumar, *ACS Appl. Mater. Interfaces*, 2012, **4**, 2717–2725.
- I. M. Szilagyi, B. Forizs, O. Rosseler, A. Szegedi, P. Nemeth,
 P. Kiraly, G. Tarkanyi, B. Vajna, K. Varga-Josepovits,
 K. Laszlo, A. L. Toth, P. Baranyai and M. Leskela, *J. Catal.*, 2012, 294, 119–127.
- 20 X. F. Ning and G. X. Lu, Nanoscale, 2020, 12, 1213-1223.
- 21 A. R. Amani-Ghadim, F. Khodam and M. S. S. Dorraji, J. Mater. Chem. A, 2019, 7, 11408–11422.
- 22 A. Kudo and Y. Miseki, Chem. Soc. Rev., 2009, 38, 253-278.
- 23 H. Y. Liu, C. L. Yang, M. S. Wang and X. G. Ma, *Appl. Surf. Sci.*, 2020, **501**, 7.
- 24 J. Q. Wen, J. Xie, X. B. Chen and X. Li, *Appl. Surf. Sci.*, 2017, 391, 72–123.
- 25 S. W. Cao and J. G. Yu, J. Phys. Chem. Lett., 2014, 5, 2101–2107.
- 26 X. Y. Du, X. Bai, L. Xu, L. Yang and P. K. Jin, *Chem. Eng. J.*, 2020, **384**, 14.
- 27 Y. H. Li, M. L. Gu, T. Shi, W. Cui, X. M. Zhang, F. Dong, J. S. Cheng, J. J. Fan and K. L. Lv, *Appl. Catal.*, *B*, 2020, 262, 11.
- 28 S. Lin, X. X. Ye, X. M. Gao and J. Huang, J. Mol. Catal. A: Chem., 2015, 406, 137–144.
- 29 A. V. Bandura, D. D. Kuruch and R. A. Evarestov, *Isr. J. Chem.*, 2017, 57, 490–500.
- 30 M. Isik and N. M. Gasanly, *Mater. Sci. Semicond. Process.*, 2020, **107**, 5.

- 31 R. Q. Zhang, L. L. Zhang, Q. J. Zheng, P. F. Gao, J. Zhao and J. L. Yang, *J. Phys. Chem. Lett.*, 2018, 9, 5419–5424.
- 32 X. Yan, C. S. Liu, C. Li, W. Z. Bao, S. J. Ding, D. W. Zhang and P. Zhou, *Small*, 2017, **13**, 8.
- 33 L. J. Sham and W. Kohn, Phys. Rev., 1966, 145, 561-567.
- 34 G. Kresse and J. Furthmuller, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1996, **54**, 11169–11186.
- 35 G. R. Su, S. Yang, S. Li, C. J. Butch, S. N. Filimonov, J. C. Ren and W. Liu, *J. Am. Chem. Soc.*, 2019, **141**, 1628–1635.
- 36 J. P. Perdew, K. Burke and M. Ernzerhof, *Phys. Rev. Lett.*, 1996, 77, 3865–3868.
- 37 J. Heyd, G. E. Scuseria and M. Ernzerhof, *J. Chem. Phys.*, 2003, **118**, 8207–8215.
- 38 P. Umari, G. Stenuit and S. Baroni, Phys. Rev. B: Condens. Matter Mater. Phys., 2009, 79, 4.
- 39 P. Umari, G. Stenuit and S. Baroni, Phys. Rev. B: Condens. Matter Mater. Phys., 2010, 81, 5.
- 40 E. E. Salpeter and H. A. Bethe, Phys. Rev., 1951, 84, 1232-1242.
- 41 S. Grimme, J. Comput. Chem., 2006, 27, 1787-1799.
- 42 M. M. Dong, C. He and W. X. Zhang, *J. Mater. Chem. C*, 2017, 5, 3830–3837.
- 43 M. Ganaie and M. Zulfequar, J. Alloys Compd., 2016, 687, 643–651.
- 44 C. He, J. H. Zhang, W. X. Zhang and T. T. Li, J. Phys. Chem. C, 2019, 123, 5157–5163.
- 45 C. He, J. H. Zhang, W. X. Zhang and T. T. Li, *J. Phys. Chem. Lett.*, 2019, **10**, 3122–3128.
- 46 S. Bruzzone and G. Fiori, Appl. Phys. Lett., 2011, 99, 3.

- 47 S. Takagi, A. Toriumi, M. Iwase and H. Tango, *IEEE Trans. Electron Devices*, 1994, 41, 2357–2362.
- 48 G. Fiori and G. Iannaccone, Proc. IEEE, 2013, 101, 1653–1669.
- 49 J. S. Qiao, X. H. Kong, Z. X. Hu, F. Yang and W. Ji, Nat. Commun., 2014, 5, 7.
- 50 H. L. L. Zhuang and R. G. Hennig, *Chem. Mater.*, 2013, 25, 3232-3238.
- 51 H. C. Yang, J. J. Li, L. Yu, B. B. Huang, Y. D. Ma and Y. Dai, J. Mater. Chem. A, 2018, 6, 4161–4166.
- 52 R. M. N. Yerga, M. C. A. Galvan, F. del Valle, J. A. V. de la Mano and J. L. G. Fierro, *ChemSusChem*, 2009, 2, 471–485.
- 53 T. Low, A. S. Rodin, A. Carvalho, Y. J. Jiang, H. Wang, F. N. Xia and A. H. C. Neto, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2014, **90**, 5.
- 54 Y. N. Zhang, J. N. Yun, K. Y. Wang, X. H. Chen, Z. Yang, Z. Y. Zhang, J. F. Yan and W. Zhao, *Comput. Mater. Sci.*, 2017, **136**, 12–19.
- 55 J. N. Hilfiker, M. Stadermann, J. N. Sun, T. Tiwald, J. S. Hale, P. E. Miller and C. Aracne-Ruddle, *Appl. Surf. Sci.*, 2017, **421**, 508–512.
- 56 S. Kattel, P. Atanassov and B. Kiefer, *Phys. Chem. Chem. Phys.*, 2013, **15**, 148–153.
- 57 J. Rossmeisl, Z. W. Qu, H. Zhu, G. J. Kroes and J. K. Norskov, *J. Electroanal. Chem.*, 2007, **60**7, 83–89.
- 58 J. Rossmeisl, A. Logadottir and J. K. Norskov, *Chem. Phys.*, 2005, **319**, 178–184.
- 59 A. Valdes, Z. W. Qu, G. J. Kroes, J. Rossmeisl and J. K. Norskov, J. Phys. Chem. C, 2008, 112, 9872–9879.